Erratum: “Thickness-driven antiferroelectric-to-ferroelectric phase transition of thin PbZrO$_3$ layers in epitaxial PbZrO$_3$/PbZr$_{0.8}$Ti$_{0.2}$O$_3$ multilayers” [Appl. Phys. Lett. 91, 122915 (2007)]

Ksenia Boldyreva$^a$
Max Planck Institute of Microstructure Physics, Weinberg 2, D-06120 Halle (Saale), Germany

Lucian Pintilie
Max Planck Institute of Microstructure Physics, Weinberg 2, D-06120 Halle (Saale), Germany and NIMP,
P.O. Box MG-7, 077125 Bucharest-Magurele, Romania

Andriy Lotnyk, I. B. Misirlioglu, Marin Alexe, and Dietrich Hesse
Max Planck Institute of Microstructure Physics, Weinberg 2, D-06120 Halle (Saale), Germany

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In the last paragraph (conclusion section) of the above-mentioned letter, the first sentence should read as follows: “In conclusion, a thickness-driven antiferroelectric-to-ferroelectric, orthorhombic-to-rhombohedral phase transition of the PbZrO$_3$ layers in epitaxial antiferroelectric/ferroelectric PbZrO$_3$/PbZr$_{0.8}$Ti$_{0.2}$O$_3$ multilayers has been observed at a PbZrO$_3$ thickness below 10 nm.”, in accordance with the entire contents of the letter and the last but one sentence of the abstract.

$^a$Electronic mail: ksenia@mpi-halle.de